



**HAL**  
open science

## Ultrafast dynamics of hot carriers in a quasi-two-dimensional electron gas on InSe

Zhesheng Chen, Jelena Sjakste, Jingwei Dong, Amina Taleb-Ibrahimi, Jean-Pascal Rueff, Abhay Shukla, Jacques Peretti, Evangelos Papalazarou, Marino Marsi, Luca Perfetti

► **To cite this version:**

Zhesheng Chen, Jelena Sjakste, Jingwei Dong, Amina Taleb-Ibrahimi, Jean-Pascal Rueff, et al.. Ultrafast dynamics of hot carriers in a quasi-two-dimensional electron gas on InSe. Proceedings of the National Academy of Sciences of the United States of America, 2020, 117 (36), pp.21962-21967. 10.1073/pnas.2008282117 . hal-03049219

**HAL Id: hal-03049219**

**<https://hal.science/hal-03049219v1>**

Submitted on 9 Dec 2020

**HAL** is a multi-disciplinary open access archive for the deposit and dissemination of scientific research documents, whether they are published or not. The documents may come from teaching and research institutions in France or abroad, or from public or private research centers.

L'archive ouverte pluridisciplinaire **HAL**, est destinée au dépôt et à la diffusion de documents scientifiques de niveau recherche, publiés ou non, émanant des établissements d'enseignement et de recherche français ou étrangers, des laboratoires publics ou privés.

# Ultrafast dynamics of hot carriers in a quasi-two-dimensional electron gas on InSe

Zhesheng Chen<sup>1</sup>, Jelena Sjakste<sup>1</sup>, Jingwei Dong<sup>1</sup>, Amina Taleb-Ibrahimi<sup>2</sup>, Jean-Pascal Rueff<sup>2</sup>,  
Abhay Shukla<sup>3</sup>, Jacques Peretti<sup>4</sup>, Evangelos Papalazarou<sup>5</sup>, Marino Marsi<sup>5</sup> and Luca Perfetti<sup>1</sup>

<sup>1</sup> *Laboratoire des Solides Irradiés, CEA/DRF/IRAMIS, CNRS,*

*Ecole polytechnique, Institut Polytechnique de Paris, 91128 Palaiseau, France*

<sup>2</sup> *Société civile Synchrotron SOLEIL, L'Orme des Merisiers,  
Saint-Aubin - BP 48, 91192 Gif-sur-Yvette, France*

<sup>3</sup> *Institut de Minéralogie, de Physique des Matériaux et de Cosmochimie,  
CNRS-UMR7590, Sorbonne Université, 4 Place Jussieu, Paris 75252, France*

<sup>4</sup> *Laboratoire de Physique de la Matière Condensée, Ecole polytechnique,  
CNRS, CEA, Université Polytechnique de Paris, 91128 Palaiseau, France and*

<sup>5</sup> *Laboratoire de Physique des Solides, CNRS, Université Paris-Sud, Université Paris-Saclay, 91405 Orsay, France*

Two dimensional electron gases (2DEGs) are at the base of current nanoelectronics because of their exceptional mobilities. Often the accumulation layer forms at polar interfaces with Longitudinal Optical (LO) modes. Fortunately, the many-body screening of the quasi-2DEGs dramatically reduces the Fröhlich scattering strength. Despite the effectiveness of such process, it has been recurrently proposed that a remote coupling with LO phonons persists even at high carrier concentration. The experimental evidence of this interaction has until now remained elusive. Here, we report the first time resolved spectroscopy of a quasi-2DEG relaxation after perturbation by an ultrafast laser pulse. The cooling rate of excited carriers is monitored at doping level spanning from the classical to the full quantum limit. We observe that quantum screening of LO phonons is not as efficient as it would be in a strictly 2D dimensional system. The large discrepancy is due to the remote coupling of confined states with the bulk. Our data indicate that the effect of such a remote coupling can be mimicked by a 3D Fröhlich interaction with Thomas-Fermi screening. These conclusions are very general and should apply to field effect transistors (FET) with high- $\kappa$  dielectric gates, van der Waals heterostructures and metallic interfaces between insulating oxides.

PACS numbers:

The low energy consumption in integrated circuits would not be possible if the carriers of field effect transistors (FET) would not show exceptional mobility. By the same token, the two dimensional electron gas (2DEG) in accumulation layers has been an ideal platform where to observe the quantum hall effect<sup>1</sup>. Nowadays, 2DEG are employed for computing<sup>2</sup>, metrology<sup>3</sup>, spin to charge conversion<sup>4</sup> and optoelectronics<sup>5</sup>. Usually, these low dimensional channels spontaneously form or can be electrostatically induced at the interface of polar materials. Some notable examples are Si/SiO<sub>2</sub>/HfO<sub>2</sub><sup>6</sup>, InGaAs/Al<sub>2</sub>O<sub>3</sub><sup>7</sup>, LaAlO<sub>3</sub>/SrTiO<sub>3</sub><sup>8</sup> and MoS<sub>2</sub> / SiO<sub>2</sub><sup>9</sup>. At these interfaces the longitudinal optical (LO) phonons interact with carriers via long range Fröhlich coupling<sup>10</sup>. The polar scattering can limit the electron mobility if electrons attain a temperature comparable to the LO phonon frequency. Even if electronic screening drastically reduces the strength of the Fröhlich interaction<sup>11</sup>, the quasi-2DEG can still suffer from Coulomb scattering with dipoles of the surrounding medium. Such a remote interaction is known to affect the mobility of few layer devices covered by charged impurities<sup>12</sup> and it can also act on LO phonons of a polar medium<sup>12,13</sup>. The remote LO coupling is of major concern in gate insulators with a high relative dielectric constant. New FET devices based on high- $\kappa$  gates are partially replacing silicon dioxide<sup>6</sup> and have been already integrated in aggressively scaled complementary metal oxide semiconductors (CMOS).

In order to uncover the relevance of remote phonon

coupling, we perform here the first ultrafast spectroscopy of an accumulation layer. The quasi-2DEG is obtained by evaporating cesium (Cs) atoms on the surface of indium selenide (InSe) at low temperature and in ultra-high vacuum conditions. This doping method simulates with good accuracy the electrostatic gating and can be easily implemented in our experiment<sup>14</sup>. The choice of polar material is motivated by the fact that InSe is one of the best van der Waals structures for the fabrication of FET devices<sup>15,16</sup>. It has an electronic gap comparable to silicon<sup>17</sup>, small effective mass<sup>18</sup>, layered structure<sup>19</sup> and carrier mobility higher than transition metal dichalcogenides<sup>16</sup>. The electronic state and distribution function of hot electrons in the accumulation layer is directly monitored by time and angle resolved photoelectron spectroscopy (tr-ARPES). Our approach offers exceptional advantages such as: i) the probing depth is comparable to the localization length of the quasi-2DEG<sup>20</sup>; ii) the momentum selectivity reveals if excited electrons are in extended bulk states or in confined 2D states<sup>21</sup>; iii) the electronic distribution discriminates between the classical and quantum regime of hot carriers; iv) the electronic cooling is slower than the typical pulse duration of mode-locked laser pulses<sup>18,22-24</sup>. By monitoring all relevant parameters, the tr-ARPES data allow for an extraction of the experimental cooling rate and for a direct comparison with model calculations of screened Fröhlich interaction. As a result, the presence of remote phonon coupling can be explicitly identified and quanti-

fied.

Single crystals of  $\varepsilon$ -InSe have been grown using the Bridgmann method from a non-stoichiometric melt<sup>25</sup>. ARPES and photoluminescence spectra show that our bulk crystal is naturally  $n$ -doped and has direct band gap of  $\sim 1.28$  eV<sup>17</sup>. All samples have been cleaved at the base pressure of  $8 \times 10^{-11}$  mbar and exposed to an atomic jet of Cs. After each exposure to the alkali vapor, we performed tr-ARPES of the surface. For the entire duration of the experiment, the sample is kept at the base temperature of 125 K.

The photon source for tr-ARPES experiments is a Ti:Sapphire laser system delivering  $6 \mu\text{J}$  pulses with repetition rate of 250 kHz. Part of the fundamental beam ( $\omega = 1.55$  eV) is employed to pump the sample with incident fluence  $0.8 \text{ mJ}/\text{cm}^2$  while the rest is employed to generate the fourth harmonic beam ( $4\omega = 6.2$  eV)<sup>26</sup>. The electrons are emitted by the  $4\omega$  pulses incident on the sample at  $45^\circ$  and  $p$ -polarization. An electrostatic analyzer discriminates the photoelectrons in kinetic energy and emission angle with a resolution of 50 meV and 0.5 degrees, respectively. Independently of the configuration of the experiment, the two beams generating the tr-ARPES signal display a cross correlation with full width at half maximum (FWHM)  $< 0.15$  ps.

We suddenly inject hot carriers in the conduction band by photoexciting the sample via an ultrafast laser pulse centered at 1.55 eV. Since InSe has a direct electronic gap of  $\sim 1.28$  eV, the excited carriers attain a maximal excess energy of 0.3 eV. The electron-electron interaction efficiently redistributes the energy density in the accumulation layer. As shown in Fig. 1B,C, the electronic distribution at pump-probe delay of 0.1 ps matches well a thermalized state with effective electronic temperature  $T_e$ . The only notable exception is observed on the pristine surface ( $E_F = 10$  meV), where the distribution near the conduction band minimum differs from the one expected from a thermal gas. We estimate the electronic temperature for each  $E_F$  by fitting the high energy tail of the excited electronic spectrum with a Fermi-Dirac function. In addition, the average excess energy in the electron gas is obtained by calculating the integral:

$$E_x(t) = \frac{\int E |I(E, t) - I(E, -)| dE}{\int |I(E, t) - I(E, -)| dE},$$

where  $I(E, t)$  is the angle integrated spectrum at delay time  $t$  while  $I(E, -)$  is the angle integrated spectrum at negative delay. The integration range is between -0.3 and 0.3 eV.

As shown in Fig. 1D the  $E_x$  at 0.1 ps scales as  $(1.3 \pm 0.1)k_b T_e$  within the entire doping range and decreases by 70% at high Cs concentration. Since the inci-

Due to a downward band bending of roughly 150 meV (see supplementary information<sup>27</sup>), the chemical potential of a freshly cleaved surface lies 10 meV above the conduction band minimum. Accumulation layers with different charge concentration are obtained via subsequent exposure of the surface to Cs vapor. By increasing the density of the absorbed alkali atoms, the Fermi Energy  $E_F$  of the electrons can be varied from 10 meV up to 200 meV (see Fig. 1A). These 2D states penetrate the interface over a distance of several nanometers but are highly dispersive in the surface plane. At the highest doping level an additional feature can be observed near zero wavevector and zero energy. These states could be the bottom of the underlying 3D conduction band or the second subband of the quasi-2DEG. In one case as in the other, the occurrence of an extra band is in agreement with the 2D quantization of the electronic states in the confining potential. It is instructing to estimate the maximal carrier density  $\rho_M$  in the accumulation layer. Since the effective mass of the quasi-2DEG is 10 times smaller than the one of a free electron, we find  $\rho_M = 9 \times 10^{12} \text{ 1}/\text{cm}^2$  for  $E_F = 200$  meV. The  $\rho_M$  value is comparable to the maximal doping level achieved via electrostatic gating<sup>16</sup>. At even higher alkali concentration the surface of InSe becomes unstable and the quasi-2DEG disappears<sup>17</sup>.

dent pump pulse has always the same fluence, this drop is due to the energy redistribution between a fixed amount of photoexcited carriers and the increasing number of electrons in the accumulation layer. As a consequence, the parameter  $\gamma = E_x/E_F$  spans from the classical statistical regime ( $\gamma = 10$ ) to the quantum statistical regime of a deeply degenerate quasi-2DEG ( $\gamma = 0.2$ ). When the electronic density in accumulation level increases, three effects reduce the energy dissipation of the photoexcited gas: i) the metallic electrons efficiently screens the long range Fröhlich interaction between electrons and LO phonons, ii) the Fermi statistics hinders dissipation channels near to the chemical potential and, iii) the average excess energy of the electrons approaches the threshold value for an emission of LO phonons.

On equal footing, the surface doping also induces a dimensionality crossover of the hot carriers. When  $E_F$  is small compared to  $E_x$ , the confining potential plays the role of a small perturbation. Therefore, hot electrons occupy bulk like states with 3D character. Conversely, the 2D confinement becomes effective once the  $E_F$  is larger than the average excess energy. At  $E_F > 100$  meV hot electrons with low  $E_x$  accumulate in wavefunctions that extend only few nanometers in the bulk. Although an effective dimensionality of hot electrons is not sharply defined, we remark that  $\gamma = E_x/E_F$  is a meaningful measure of the 3D-2D crossover.

The full dynamics of hot electrons elucidate the evolu-

tion of cooling process at different doping levels. Figure

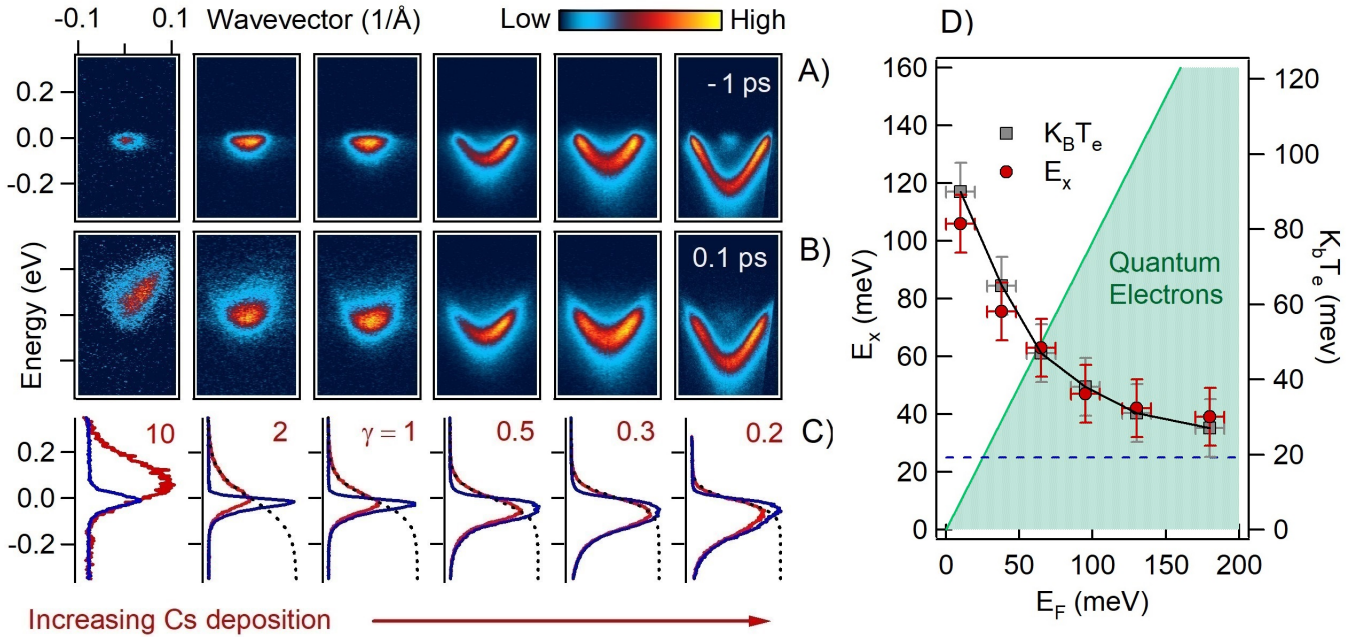


FIG. 1: A) Photoelectron intensity maps acquired at negative pump-probe delay. B) Photoelectron intensity maps acquired at delay time of 0.1 ps. C) Wavevector integrated intensity at negative delay time (blue curve) and 0.1 ps after photoexcitation (red curve). The black dashed curve is the estimated Fermi-Dirac distribution. We indicate with  $\gamma$  the ratio between the average excess energy  $E_x$  and the Fermi energy  $E_F$ . Here  $E_F$  is the energy distance between the bottom of the dispersing parabola and the chemical potential in the low temperature limit (zero of the energy axis). Panels of each line have been acquired for a given exposure to the Cs vapor. From up to down, the Fermi energy of the electron gas is  $E_F = 10, 40, 65, 95, 130, 200$  meV. D) Average excess energy (red circles) and electronic temperature (gray squares) as a function of Fermi energy. The green area indicate the region where the average excess energy of electrons becomes lower than the Fermi energy. The dashed blue line indicates the threshold electron energy for LO phonon emission.

2A shows the differential signal obtained by subtracting the map acquired at negative to the one acquired at positive values of the pump-probe delay. Blue and red colors stand for photoexcited electrons and holes in the electronic system, respectively. These panels offer a visual guide of the electronic cooling for three indicative densities ( $E_F = 10, 40, 130$  meV). A qualitative analysis of the differential intensity maps provides clear evidence of the dimensionality crossover. Note that excited electrons are distributed in a broad area of reciprocal space when  $E_F = 10$  meV. This signal originates from many 3D states with different values of the perpendicular wavevector  $k_z$ . Since these 3D states disperse along the  $z$  axis, the excited electrons cover part of the projected band structure. In contrast, when  $E_F = 130$  meV the differential intensity is concentrated along a nearly free electron parabola that has no measurable dispersion in the  $z$  direction. From this map, we deduce that hot electrons become confined in the high doping regime.

Figure 2B plots the temporal evolution of the excess energy normalized to its maximal value. Initially, the excited electrons experience a subpicosecond relaxation due to emission of LO phonon with small momentum transfer. After 1-2 ps, such subset of phonon modes enters in

equilibrium with hot electrons. The subsequent dynamics is dictated by anharmonic decay of the hot optical phonons in to lattice modes of lower energy. Here we are interested only in the relaxation at early delay, namely when LO phonons are still near to equilibrium conditions. As shown in Fig. 2B, the initial cooling time  $\tau$  becomes twice slower at high carrier concentration. Measurements on two different cleaves confirm that  $\tau$  is roughly 0.4 ps in the pristine surface, while it saturates to 0.8 ps upon increasing the concentration of absorbed Cs (see Fig. 2C). We estimate the cooling rate  $\eta$  of the electronic system as the average excess energy at 0.1 ps divided by cooling time  $\tau$ . Figure 3A shows that this rate decreases by nearly one order of magnitude when moving from the classical to the quantum regime.

In order to simulate the cooling rate, we calculated the phonon spectrum by density functional perturbation theory (DFPT) (see Fig. 3B). We identify for each direction in wavevector space the polar and the non-polar branches. Since the excited electrons have small wavevector, the phonon emission is limited to a wavevector transfer  $q < 0.2$  1/Å. The unscreened scattering with polar optical is long ranged and diverges for small wavevector transfer<sup>30</sup>. As a consequence, we expect LO emission

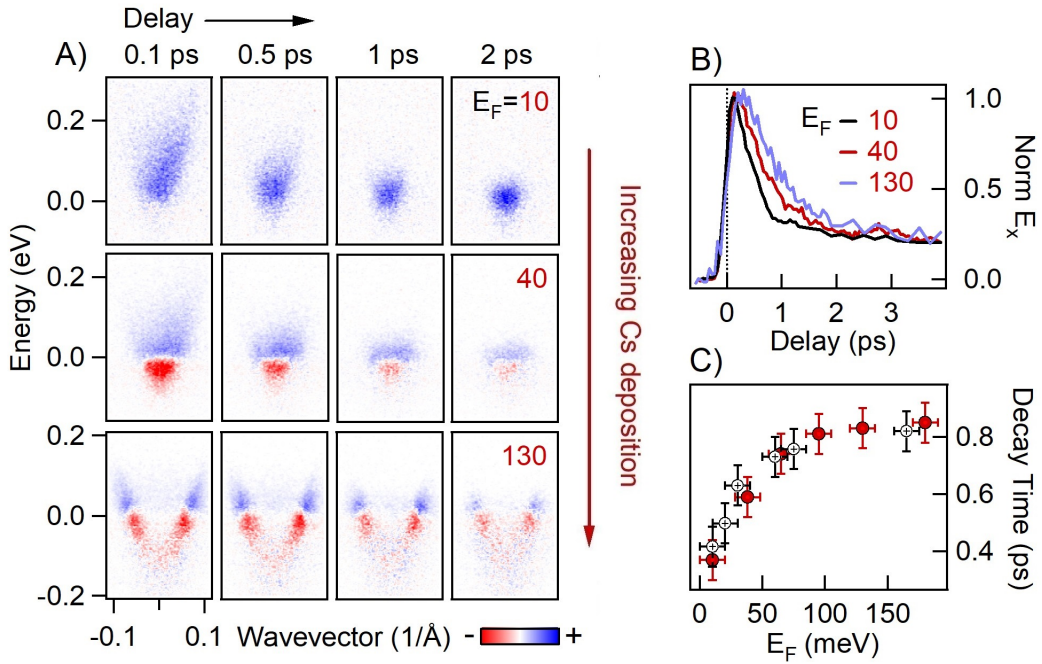


FIG. 2: A) Differential intensity maps obtained by subtracting the photoelectron intensity at negative delay from the photoelectron intensity at positive delay. The panels from left to right display data acquired at increasing delay time after photoexcitation. Top, middle and bottom columns correspond to an electron gas with Fermi energy  $E_F = 10, 40, 130$  meV. B) Temporal evolution of the average excess energy  $E_x$  in the electron gas with different Fermi Energy. The curves have been normalized to the maximal  $E_x$  value for better comparison. C) Initial decay time of average excess energy versus the Fermi energy. Filled and open symbols indicate the results of two independent set of measurements.

to be the largely dominant electron-phonon scattering mechanism. This is a general property of polar semiconductors, such as for example GaAs<sup>29</sup>. To illustrate this point, we show on Fig. 3C the strength of the electron-phonon matrix elements for all phonon modes of  $\varepsilon$ -InSe. Figure 3C shows that the coupling of the  $E'$  polar mode is in average more than 10 times larger than the one of the best coupled non-polar mode (the mode with  $A'_1$  symmetry). The contribution of the polar coupling to the energy relaxation rate scales as coupling matrix element squared, being at least 100 times larger than the  $A'_1$  non-polar one. With respect to the other non-polar modes this ratio becomes even larger, so that the black curves in Fig. 3C collapse to values near to the ordinate axis. Figure 3C also show that the matrix elements of the polar  $E'$  mode nearly follow the  $q$  dependence predicted by the Vogl's model<sup>30</sup>. We make use of this result to extrapolate the polar phonon coupling that is calculated by *ab initio* DFPT on a denser grid of wavevectors, .

We simulate the cooling rate  $\eta$  due to Fröhlich interaction by calculating<sup>31</sup> as

$$\eta = (1 - f(E_x - \hbar\Omega_{em}))\Omega_{em}\Gamma_{em} - (1 - f(E_x + \hbar\Omega_{abs}))\Omega_{abs}\Gamma_{abs} \quad (1)$$

Here,  $f$  is Fermi-Dirac distribution function which de-

pends on the electronic temperature  $T_e$  and on the chemical potential,  $\Gamma_{em}$  and  $\Gamma_{abs}$  are the total probabilities for emission and absorption, while  $\Omega_{em}$  and  $\Omega_{abs}$  are effective LO phonon frequencies for emission and absorption (see supplementary information for details about the calculations<sup>27</sup>). For each value of the Fermi energy  $E_F$ , we extract the electronic temperature  $T_e$  from the experimental curve in Fig. 1D and derive the chemical potential  $\mu$  on the base of a free electron model<sup>32</sup>. The value of  $\Gamma_{em}$  and  $\Gamma_{abs}$  strongly depend on the electron-phonon coupling strength of the polar modes. The non-polar modes would contribute to the cooling rate with an extra term below 0.01 eV/ps and can be neglected with respect to the emission of LO optical phonons. First we consider the case of a 3D electron gas with unscreened Fröhlich interaction. As already shown by our previous work on the pristine surface<sup>18</sup>, this approach provides an estimated value of the cooling rate that is in agreement with tr-ARPES experiments. Upon increasing the doping level, a moderate decrease of the calculated  $\eta$  takes place at the crossover from a classical to a quantum statistic. Nonetheless, this unscreened coupling badly overestimates the experimental behavior even at moderate carriers concentration (see red dotted curve in Fig. 3A).

In order to explain the experimental data, we consider

a 3D model of the Fröhlich interaction<sup>30</sup> with Thomas-



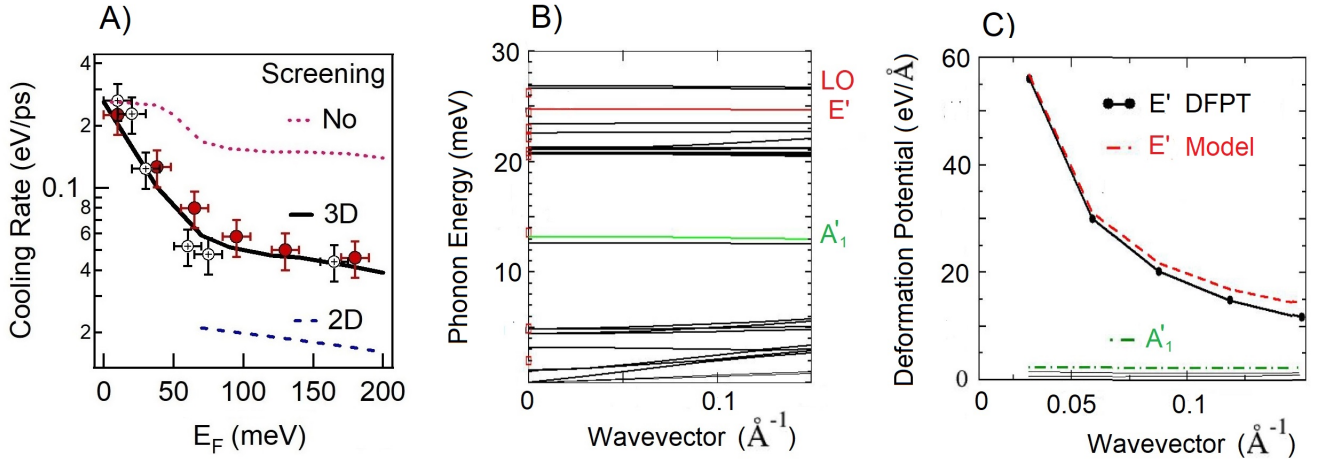


FIG. 3: A) Electronic cooling rate  $\eta$  as a function of Fermi energy. Filled and open symbols represent data from two independent set of measurements. The black solid, dashed blue and dotted red curves are the cooling rates calculated by an ab-initio model with 3D, 2D and no screening of the Fröhlich interaction, respectively. B) Calculated phonon dispersion of  $\epsilon$ -InSe in  $\Gamma - M$  direction of the Brillouin zone. Polar optical mode  $E'$  is shown in red, while the acoustical  $A'_1$  mode is shown in green. Red squares at  $q = 0$  stand for experimental from Ref.<sup>28</sup>. C) Calculated electron-phonon deformation potentials as a function of the phonon wavevector  $\mathbf{q}$  along the  $\Gamma - M$  direction. The initial electronic state is in the conduction band at  $\mathbf{k} = (0, 0.11, 0) \frac{2\pi}{a}$ . For the polar mode, both the results of the DFPT (Black circles) and Vogl model (red dotted line) are shown.

Fermi screening. We expect these simulations to be accurate for the regime  $\gamma < 1$ , namely when hot electrons retain their 3D character. Surprisingly, the black line in Fig. 3A shows that the screened 3D interaction matches well the experimental data even in the case of a quasi-2DEG. This result needs to be carefully addressed, since a dimensionality crossover towards 2D states is observed in photoelectron intensity maps with  $\gamma > 1$ . In order to gain more insights, we compute the  $\eta$  expected in a strictly two dimensional system with 2D Fröhlich coupling<sup>10</sup> and 2D dielectric screening<sup>11</sup>. The perfect confinement of the ideal system does cut off the divergence of the polar interaction at small wavevector. Moreover, the electron-hole excitations that are responsible for the screening response acquire a higher density in the phase space (consider that in a strictly 1D system the collective excitations become so strong even the Fermi liquid picture breaks down). As a consequence, the  $\eta$  of a strictly 2D model drops dramatically already a small doping level. It is clear from the dashed blue line of Fig. 3A that such model grossly underestimates the experimental cooling rate. The difference between the 2D model and experimental data is ascribed to a remote coupling between the quasi-2DEG and 3D phonons. The exact mechanism is still not identified. It could be an energy transfer mediated by surface plasmons-polaritons or any other channel that couples the confined electrons with LO modes that are not strictly two dimensional. An accurate simulation of such remote interaction would be a challenging task which is

beyond the scope of the present work. However, Fig. 3A shows that a 3D model with Thomas Fermi screening already reproduces remarkably well the experimental data.

In conclusion, hot electrons in quasi-2DEGs display a remote coupling to polar optical phonons persisting up to high electronic density. The accurate modeling of such interaction should include the wavefunctions of confined 2D electrons, dynamical screening effects, surface plasmons polaritons and interface phonons. Nonetheless, the static screening of bulk phonons by 3D electrons can quantitatively reproduce the experimental cooling rate. This finding highlights that electrons in accumulation layers or 2D conductors at the interface with a polar medium experience 3D dissipation channels. The outcome is of high relevance for the carriers mobility in FET devices with high  $\kappa$  dielectric gates, van der Waals heterostructures and 2DEGs at the interface between oxides.

We acknowledge enlightening discussions with Matteo Calandra and Valerie Veniard. Many thanks to the Ecole Polytechnique for funding under the project ECOGAN, the Chaire Energie Durable. Financial support has been given by the DGA project ITEHR (No. 2018 60 0074) and by the EU/FP7 program under the contract Go Fast (Grant No. 280555). Computer time has been granted by the national centers GENCI-CINES and GENCI-TGCC (Project 2210), and by Ecole Polytechnique through the LLR-LSI project. Computational results have been obtained via the QUANTUM ESPRESSO code<sup>34</sup>.

<sup>1</sup> K. V. Klitzing, G. Dorda and M. Pepper, Phys. Rev. Lett. **45**, 494 (1980).

<sup>2</sup> R. Chau, B. Doyle, S. Datta, J. Kavalieros and K. Zhang,

- Nat. Mater. **6**, 810 (2007).
- <sup>3</sup> B. Jeckelmann and B. Jeanneret, Rep. Prog. Phys. **64**, 1603 (2001).
  - <sup>4</sup> E. Lesne, Y. Fu, S. Oyarzun, J. C. Rojas-Sánchez, D. C. Vaz, H. Naganuma, G. Sicoli, J.-P. Attané, M. Jamet, E. Jacquet, J.-M. George, and A. Barthélémy, and H. Jaffrès, A. Fert, M. Bibes and L. Vila, Nat. Mater. **15**, 1261 (2016).
  - <sup>5</sup> A. Liu, R. Jones, L. Liao, D. Samara-Rubio, D. Rubin, O. Cohen, R. Nicolaescu and M. Panizza, Nature **427**, 615 (2004).
  - <sup>6</sup> M. Houssa, High  $\kappa$  dielectrics (Institute of Physics Publishing, Bristol and Philadelphia, 2004).
  - <sup>7</sup> J. A. del Alamo, Nature **479**, 317 (2011).
  - <sup>8</sup> A. Ohtomo and H. Y. Hwang, Nature **427**, 423 (2004).
  - <sup>9</sup> B. Radisavljevic, A. Radenovic, J. Brivio, V. Giacometti and A. Kis, Nat. Nanotechnol. **6**, 147 (2011).
  - <sup>10</sup> T. Sohier, M. Calandra and F. Mauri, Phys. Rev. B **94**, 085415 (2016).
  - <sup>11</sup> F. Stern, Phys. Rev. Lett. **18**, 546 (1967).
  - <sup>12</sup> J.-H. Chen, C. Jang, S. Xiao, M. Ishigami and M. S. Fuhrer, Nat. Nanotechnol. **3**, 206 (2008).
  - <sup>13</sup> M. V. Fischetti, D. A. Neumayer, and E. A. Cartier, J. Appl. Phys. **90**, 4587 (2001).
  - <sup>14</sup> J. Kim, S. S. Baik, S. H. Ryu, Y. Sohn, S. Park, B.-G. Park, J. Denlinger, Y. Yi, H. J. Choi and K. S. Kim, Science **349**, 723 (2015).
  - <sup>15</sup> Z. Chen, J. Biscaras, and A. Shukla, Nanoscale **7**, 5981 (2015).
  - <sup>16</sup> D. A. Bandurin, A. V. Tyurnina, G. L. Yu, A. Mishchenko, V. Zólyomi, S. V. Morozov, R. K. Kumar, V. Gorbachev, Z. R. Kudrynskiy, S. Pezzini, Z. D. Kovalyuk, U. Zeitler, K. S. Novoselov, A. Patanè, L. Eaves, I. V. Grigorieva, V. I. Fal'ko, A. K. Geim and Y. Cao, Nat. Nanotechnol. **12**, 223 (2017).
  - <sup>17</sup> Z. Zhang, Z. Chen, M. Bouaziz, C. Giorgetti, H. Yi, J. Avila, B. Tian, A. Shukla, L. Perfetti, D. Fan, Y. Li and A. Bendounan, ACS Nano **13**, 13486 (2019).
  - <sup>18</sup> Z. Chen, C. Giorgetti, J. Sjakste, R. Cabouat, V. Véniard, Z. Zhang, A. Taleb-Ibrahimi, E. Papalazarou, M. Marsi, A. Shukla, J. Peretti and L. Perfetti, Phys. Rev. B **97**, 241201(R) (2018).
  - <sup>19</sup> S. J. Magorrian, V. Zólyomi and V. I. Fal'ko, Phys. Rev. B **94**, 245431 (2016).
  - <sup>20</sup> W. Meevasana, P. D. C. King, R. H. He, S. K. Mo, M. Hashimoto, A. Tamai, P. Songsiriritthigul, F. Baumberger and Z. X. Shen, Nat. Mater. **10**, 114 (2011).
  - <sup>21</sup> D. Hsieh, Y. Xia, D. Qian, L. Wray, J. H. Dil, F. Meier, J. Osterwalder, L. Patthey, J. G. Checkelsky, N. P. Ong, A. V. Fedorov, H. Lin, A. Bansil, D. Grauer, Y. S. Hor, R. J. Cava and M. Z. Hasan, Nature **460**, 1101 (2009).
  - <sup>22</sup> E. Papalazarou, L. Khalil, M. Caputo, L. Perfetti, N. Nilforoushan, H. Deng, Z. Chen, S. Zhao, A. Taleb-Ibrahimi, M. Konczykowski, A. Hruban, A. Woloś, A. Materna, L. Krusin-Elbaum and M. Marsi Phys. Rev. Mater. **2**, 104202 (2018).
  - <sup>23</sup> Z. Chen, J. Dong, E. Papalazarou, M. Marsi, C. Giorgetti, Z. Zhang, B. Tian, J.-P. Rueff, A. Taleb-Ibrahimi and L. Perfetti, Nano Lett. **19**, 488 (2019).
  - <sup>24</sup> Z. Chen, Min-i Lee, Z. Zhang, H. Diab, D. Garrot, F. Lédée, P. Fertey, E. Papalazarou, M. Marsi, C. Ponceca, E. Deleporte, A. Tejada and L. Perfetti Phys. Rev. Mater. **1**, 045402 (2017).
  - <sup>25</sup> A. Chevy, J. Cryst. Growth **67**, 119 (1984).
  - <sup>26</sup> J. Faure, J. Mauchain, E. Papalazarou, W. Yan, J. Pinon, M. Marsi and L. Perfetti, Rev. Sci. Instrum. **83**, 043109, (2012).
  - <sup>27</sup> The supplementary information contain additional experimental data of surface photovoltage and a discussion of the band bending before and after Cs deposition, describe the coupling of polar modes, the models employed to calculate the electron-phonon matrix elements, the dielectric screening and the cooling rate.
  - <sup>28</sup> Indium selenide (InSe) phonon wavenumbers: Datasheet from Landolt-Börnstein - Group III Condensed Matter Volume 41C: Non-Tetrahedrally Bonded Elements and Binary Compounds, ed. O. Madelung, U. Rössler, M. Schulz, (1998).
  - <sup>29</sup> J. Sjakste, K. Tanimura, G. Barbarino, L. Perfetti and N. Vast, J. Phys. Condens. Matter **30**, 353001 (2018).
  - <sup>30</sup> P. Vogl, Phys. Rev. B **13**, 694 (1976).
  - <sup>31</sup> P. Allen, Phys. Rev. Lett. **59**, 1460 (1987).
  - <sup>32</sup> S. Panda and B. K. Panda, J. Phys. Condens. Matter **20**, 485201 (2008).
  - <sup>33</sup> J. Sjakste, N. Vast, M. Calandra and F. Mauri, Phys. Rev. B **92**, 054307 (2015).
  - <sup>34</sup> P. Giannozzi, O. Andreussi, T. Brumme, O. Bunau, M. B. Nardelli, M. Calandra, R. Car, C. Cavazzoni, D. Ceresoli, M. Cococcioni, et al., J. Phys. Condens. Matter **29**, 465901 (2017).